

	Class	Subclass
ISSUE CLASSIFICATION		

BEST AVAILABLE COPY

U.S. UTILITY Patent Application

HKM *AK* I.P.E. PATENT DATE
 SCANNED *AS* Q.A. *11/10*

APPLICATION NO. 09/835820	CONT/PRIOR F	CLASS 438	SUBCLASS 607	ART UNIT 2812 2825	EXAMINER 144
------------------------------	-----------------	--------------	-----------------	-------------------------------------	-----------------

APPLICANTS

Tomohisa Hoshino
Vincent Vezin
Gishi Chung

THE

Fabrication process of a semiconductor device including a CVD
Process of a metal film

ISSUING CLASSIFICATION

ORIGINAL					CROSS REFERENCE(S)								
CLASS		SUBCLASS			CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)							
INTERNATIONAL CLASSIFICATION													

☐ Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg. _____	Figs. Drwg. _____	Print Fig. _____	Total Claims _____
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) (Date)		NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____	_____ (Primary Examiner) (Date)		ISSUE FEE	
			Amount Due _____	Date Paid _____
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)		ISSUE BATCH NUMBER	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 361. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.				

Form PTO-438A
(Rev. 6/99)

FILED WITH: ☐ DISK (CRF) ☐ FICHE ☐ CD-ROM
(Attached in pocket on front inside flap)

(FACE)